

D3 7. (Twice Amended) The method of claim 5 wherein the alkoxide solution contains 1 to 50 weight percent of the metal.

REMARKS

In response to an Advisory Action mailed April 4, 2002, Applicant has submitted amendments responsive to the Examiner's comments in paragraphs 3 and 4 of the Advisory Action.

Respectfully submitted,

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CERTIFICATE OF MAILING:

I hereby certify that this correspondence is being deposited with the United States Postal Service as first class mail addressed to: Commissioner of Patents and Trademarks, Washington, D.C. 20231 on May 3, 2002.

Lynda Shapiro

May 3, 2002

Date

Attachment: VERSION WITH MARKINGS TO SHOW CHANGES MADE

VERSION WITH MARKINGS TO SHOW CHANGES MADE

IN THE SPECIFICATION

The paragraph on page 5, beginning at line 6, has been amended as follows:

The metallic or silicon oxide formed on the surface of the power may be derived from the single metallic or silicon alkoxide source or the composite sources of manganese of lithiated transition metal compound and metallic [~~or non-metallic~~] alkoxide. The thickness of the metallic oxide layer reaches up to 1 to 100nm and the quantity of metal content is ranged from 1.0 to 10 weight percent of the metallic oxide.

IN THE CLAIMS

4. (Twice Amended) The positive active material of claim 1 wherein the quantity of metal [~~or non-metal~~] content is a range of 1 to 10 weight percent of the oxide.

7. (Twice Amended) The method of claim 5 wherein the alkoxide solution contains 1 to 50 weight percent of the metal [~~or non-metal~~].